

	Type	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r D e f i n i t i o n	E r r o r s
1	BRS	18	(cmp or ("chemical mecahnical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:39			0
2	BRS	10	((cmp or ("chemical mecahnical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine)) and @pd<=20000724	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:33			0
3	BRS	767	(abrasive same size) and cmp	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:32			0
4	BRS	0	((abrasive same size) and cmp) and 438/\$.ccls	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:32			0
5	BRS	263	((abrasive same size) and cmp) and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:33			0
6	BRS	23	(cmp or ("chemical mechanical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:34			0
7	BRS	23	((cmp or ("chemical mechanical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine)) not "18"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:34			0
8	BRS	5	((cmp or ("chemical mechanical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine)) not ((cmp or ("chemical mecahnical " adj (polish\$3 or planariz\$4))) same (polycarboxylate or "ammonium polyacrylate" or polyoxethylene or alkylamine))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:34			0

	Type	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r D e f i n i t i o n	E r r o r s
9	BRS	44	((abrasive same size) and cmp) and 438/\$.ccls.) and @pd<=20000724	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:35			0
10	BRS	0	(cmp or ("chemical mecahnical " adj (polish\$3 or planariz\$4))) same ((SiN or "Si.sub.3 N.sub.4") and ( SiO2 or "SiO.sub.2" or "silicon nitride" or "silicon oxide"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/03 23:41			0